

Chemistry Report for Case # P-21-0015 (Version name 1)

General

Submitter: Designer Molecules, Inc.

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TS No.: 20KK5E

Chemist: Butler, T

Contractor Support:

PV Init (kg/yr): [REDACTED]

PV Max (kg/yr): [REDACTED]

Binding Option:

Exposure-Based Review: [REDACTED]

Manufacture:

Import:

Chemical ID

CAS Number: 2419899-87-7

Chemical Name: Amines, C36-alkylenedi-, polymers with 5,5'-[(1-methylethylidene)bis(4,1-phenyleneoxy)]bis[1,3-isobenzofurandione] and 4,4'-[2,2,2-trifluoro-1-(trifluoromethyl)ethylidene]bis[2-aminophenol]

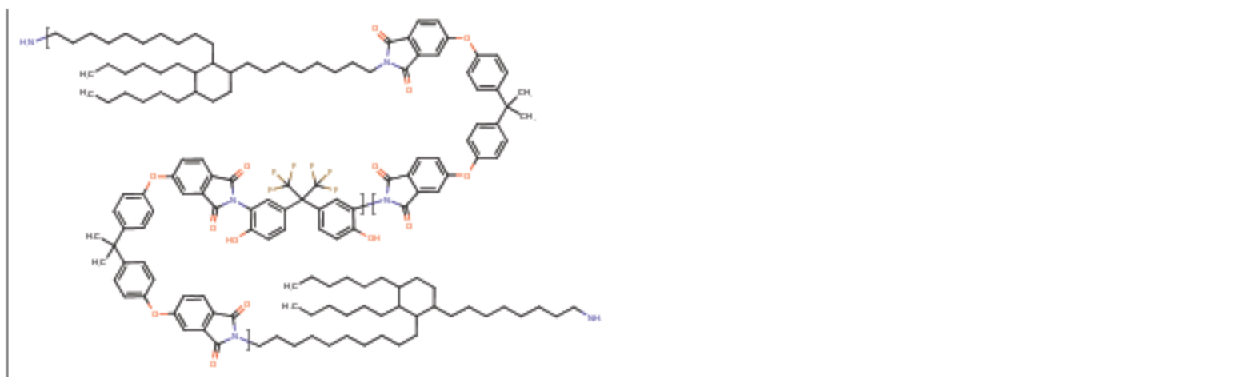
Trade Name: FM51-21, Imide Linked Polymer

IES Order: 459670

Generic Name: not CBI

Chemistry Assessor: Tristan Butler

Chemical Structure



Physical Chemical Properties

Molecular Formula: C, H, F, N, O	Molecular Weight: 37230.0
% < 500: 0.0	% < 1000: 0.0
MP:	MP Estimate: Dec. >300
BP:	BP Pressure:
BP Estimate:	
VP (Torr):	VP Estimate (Torr): <0.000001
Water Solubility (g/L):	Water Soluble Estimate (g/L): <0.000001
Log P:	Log P Estimate:
Physical State — Neat: Solid	
Physical State — Manuf: Solution: ■% PMN substance in ■	
Physical State — Processing: Dispersion: ■% PMN substance in adhesive formulation	
Physical State — End Use: Solid: PMN substance entrained in dried adhesive on silicon wafer	

Additional Chemical Info:

NAVG MW = 37230 with 0% < 500 and 0% < 1000 by multi-angle light scattering (MALS) analysis.

There is also a GPC report, but there is no molecular weight analysis provided in it.

Submitted Properties: Yellow-amber solid; decomposes above 300°C, with increased weight loss above 400°C (TGA); flash point > 250°C (Sub.Est.). An FTIR spectrum is provided. The MSDS is for a solution of the PMN substance in methoxybenzene (anisole).

Estimated Properties: VP < 0.000001 torr (High MW polymer); WS < 0.000001 g/L (high mw polymer with hydrophobic feedstocks).

Amine FGEW = [REDACTED], assuming [REDACTED] terminal amine groups.

Uses**Consumer Use?** [REDACTED]**Intended Uses (ICB):**

Intended use: Resin for temporary bonding adhesive applied to the backs of semiconductor wafers, to facilitate mechanical grinding of the wafers to reduce their thickness

Amine FGEW = [REDACTED]

Analogues (same use) [REDACTED]

Patents (same use): none.

Other Uses:

Analogues (other use) [REDACTED]

Analogues (same use and other use) [REDACTED]

Patents (other use) none

Reaction Description



Pollution Prevention Analysis(P2 Analysis:)

None.

Analogs



Comments/Telephone Log

Attachments	Update/Upload Time	Update/Upload By
P-21-0015.mol	11/09/2020 11:02	Robert Meyers

Historic Documents

Attachments	Version Number	Updated/Uploaded Time	Updated/Uploaded By
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Current Version Comments

Comment	Update/Upload Time	Update/Upload By
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